the line portion of the first metal interconnect in contact with the first material;

a first reinforcement disposed in the first material, the first reinforcement in contact with the anode section of the bottom side of the first metal interconnect, the first reinforcement comprising a second material, the second material being electrically nonconductive; and wherein the second material has a greater mechanical rigidity than the first material.

## Remarks

Claims 1 - 18 remain in the instant application. Claim 1 has been amended to more clearly point out and claim the subject matter of the instant invention. The instant application is drawn to a interconnect reinforcement placed solely at the anode terminus of a current level interconnect.

The objection to claim 1 should be withdrawn. Claim 1 has been amended to more clearly point out and claim the subject matter of the instant invention. An Appendix showing the claim in marked up format is attached.

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